

## PATENT

#28 -1a 1/23/02

## IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

APPLICANT:

HENNHÖFER ET AL.

SERIAL NO.:

09/032,305

EXAMINER: R. KUNEMUND

FILED:

FEBRUARY 27, 1998

GROUP: 1765

TITLE:

PROCESS FOR TREATING A POLISHED SEMICONDUCTOR WAFER IMMEDIATELY AFTER THE SEMICONDUCTOR WAFER

HAS BEEN POLISHED

## RESPONSE TO NONFINAL OFFICE ACTION

ATT: BOX FEE AMENDMENT

Assistant Commissioner for Patents

Washington, D.C. 20231

**RECEIVED** 

SEP 2 3 2002

TC 1700

Dear Sir:

This is in response to the Nonfinal Office Action dated April 19, 2002, with the time for reply having been extended for two months, or until September 19, 2002.

## REMARKS

Reconsideration of this patent application is respectfully requested in view of the following remarks.

The Patent Examiner has rejected claims 6, 7, and 9-16 under 35 U.S.C. 103(a) as being unpatentable over Fabray et al in view